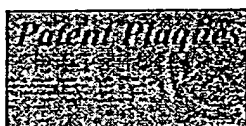


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## JP1078249A2: PHOTSENSITIVE MATERIAL AND IMAGE FORMING METHOD

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Country: JP Japan

Kind:

Inventor(s): KOIKE AKINOBU

Applicant(s): FUJI PHOTO FILM CO LTD  
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Issued/Filed Dates: March 23, 1989 / Sept. 18, 1987

Application Number: JP1987000234549

IPC Class: G03C 1/72; G03C 5/00; G03C 1/00;

Abstract: **Purpose:** To enlarge the allowable range of heating at the time of forming a negative image by providing a photosensitive layer contg. a specified compd. and an org. base, in the titled material.  
**Constitution:** The photosensitive copying material comprises the photosensitive layer consisting at least one kind of a compd. selected from the group composed of an ester and an amide of 2-benzoquinone-2-diazide-4-sulfonic acid, as an o-quinone diazide compd., and the org. base. Said material is imagewisely exposed, and then, is wholly exposed by heating, followed by developing the exposed material with an alkaline developer to remove the photosensitive layer corresponding to an unexposed part in the image-wise exposure. Thus, in the negative type image formation comprising the imagewise exposure, the heating, the whole exposure and the alkaline development, the allowable range of the heating is enlarged.  
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Family:  [Show 6 known family members](#)

Other Abstract Info: DERABS C89-107641

Foreign References: (No patents reference this one)



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